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APPLICATION NO	FILING DATE 10-31-2001	FIRST NAMED INVENTOR Eliyahou Harari	ATTORNEY DOCKET NO 11587 M-12336 US	4652

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SKJERVEN MORRILL LLP THREE EMBARCADERO CENTER, 28TH FLOOR SAN FRANCISCO, CA 94111

EXAMINER WEISS, HOWARD

PAPER NUMBER ART UNIT 2814

DATE MAILED: 01/22/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Applicant(s) Application No HARARI ET AL 10/002 696 Art Unit Office Action Summary Examiner 2814 Howard Weiss pears on the cover sheet with the correspondence address ---- The MAILING DATE of this communicate Period for Reply Y IS SET TO EXPIRE 3 MONTH(S) FROM A SHORTENED STATUTORY PERIOD FO-THE MAILING DATE OF THIS COMMUNICA 36(a) In no event, he bever, may a reply be timely filed Extensions of time may be available under the provisions. ⊋vathin the statutory r⊸minium of thirty (30) days will be considered timely after SIX (6) MONTHS from the mailing date. If this contribute all apply and will expresSIX (6) MONTHS from the mailing date of this communication If the period for reply specified above is less than thirty 30 cause the application to become ABANDONED (35 U.S.C. § 133). If NO period for reply is specified above, the maximum state : date of this of mmure lation, even if timely filed, may reduce any Failure to reply within the set or extended period for reply Any reply received by the Office later than three months, at earned patent term adjustment | See 37 CFR 1 704(b) Status November 2002 Responsive to communication(s) file 1)[] us action is non-final. This action is FINAL. ance except for formal matters, prosecution as to the merits is 2a) Since this application is in condition t Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. 3) closed in accordance with the practice Disposition of Claims the application 4) Claim(s) 13.15-23 and 25-36 is/are : wn from consideration. 4a) Of the above claim(s) ____ is/are 5) Claim(s) _____ is/are allowed. 6) Claim(s) 13,15-23 and 25-36 is/are re 7) Claim(s) _____ is/are objected to r election requirement. 8) Claim(s) ____ are subject to restrict. **Application Papers** 9) \square The specification is objected to by the \mathbb{S}^{-1} oted or b) objected to by the Examiner. 10) The drawing(s) filed on _____ is/are e drawing(s) be held in abeyance. See 37 CFR 1.85(a) Applicant may not request that any obje is a) approved b) disapproved by the Examiner. 11) The proposed drawing correction filed ply to this Office action. If approved corrected drawings are red aminer. 12) The oath or declaration is objected to t Priority under 35 U.S.C. §§ 119 and 120 priority under 35 U.S.C. § 119(a)-(d) or (f). 13) Acknowledgment is made of a claim t a) All b) Some * c) None of s have been received. 1. Certified copies of the priority d $\cdot_{ ext{S}}$ have been received in Application No. $____$. 2. Certified copies of the priority d rity documents have been received in this National Stage 3. Copies of the certified copies of reau (PCT Rule 17.2(a)). application from the Internati of the certified copies not received. * See the attached detailed Office action : c priority under 35 U.S.C. § 119(e) (to a provisional application). 14) Acknowledgment is made of a claim for : visional application has been received. a) The translation of the toreign land ic priority under 35 U.S.C. §§ 120 and/or 121. 15) Acknowledgment is made of a claim for . 4) Interview Summary (PTO-413) Paper No(s) Attachment(s) Notice of Informal Patent Application (PTO-152) 1) Notice of References Cited (PTO-890) 2) Notice of Draftsperson's Patent Drawing Review Fit

3) Information Disclosure Statement(s = Proj. (449, Pa.

Attorney's Docket Number: M-12336 US

Filing Date: 10/31/01

Continuing Data, none

Claimed Foreign Priority Date: none

Applicant(s): Harari et al. (Samachisa Yuan, Guterman)

Examiner: Howard Weiss

Claim Objections

- 1 Claim 28 is objected to under 37 CFR 1.75(c) as being in improper form because dependent claim cannot be dependent upon a multiple dependent claim. See MPEP § 608.01(n). Accordingly, the claim has not been further treated on the merits.
- 2. IN Claims 13 and 23. "injection or curce-side" should be changed to ---injection and source-side---. Appropriate correct on is required.

Claim Rejections - 35 USC § 112

3. The following is a quotation of the recond paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

- 4. Claim 26 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
- 5. Claim 26 recites the limitation "at least first and second gate elements" in Lines 1 and 2. There is insufficient antece lent basis for this limitation in the claim.

Claim Rejections - 35 USC § 103

6 The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in ris Office action:

(a) A patent may not be obtained thou. The invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be regatived by the manner in which the invention was made.

This application currently names and inventors. In considering patentability of the claims under 35 U.S.C. 103(a). th∈ ∈xaminer presumes that the subject matter of the various claims was commonly or ned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to : > nt out the inventor and invention dates of each claim that was not commonly owred at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e). (f) or (g) prior art under 35 U.S.C. 103(a).

7 Claims 13, 15, 17 and 18 are reje∈ ed under 35 U.S.C. 103(a) as being unpatentable over Eitan (U.S. Patent No. 6,011 25) and Reisinger (U.S. Patent No. 6,137,718)

Eitan shows most aspects of the instant invention (e.g. Figures 2 to 12) including:

- rogramming means (Column 2 Line 60 to Column 13 Line 33) supplying voltages to the gates 24, source 14 and drain 16 regions to one of two threshold levels in one of two defined portions 23 of a charge storage dielectric 18 containing silicon nitride
- reading means for reading the ⊃rogrammed values as claimed (Column 13 Line 35 to Column 17 Line 30)

Eitan does not show the storage c' more then two defined ranges. Reisinger teaches (e.g. Figure 1) to store four (Colui in 7 Lines 25 to 30) or more (Column 6 Lines 5 to 35) ranges in a charge storage di ∈ctric 52 in order to increase the storage density (Column 2 Lines 7 to 12) It would have been obvious to a person of ordinary skill in the art at the time of invention to store four or more ranges in a charge storage dielectric as taught by Reisinger the device of Eitan in order to increase the storage density

In reference to the claim language referring to how the cells are programmed (either by channel hot-electron or source side injection), intended use and other types of functional language must result in a structural difference between the claimed invention and the prior art in ordate to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim. In a claim drawn to a process of making, the intended use must result in a manipulative framework as compared to the prior art. In reaction of the instant case, the structure of the memory cells in Eitan and Reisinger show the same structure (i.e. a three is ered dielectric storage layer) and, therefore, are capable of being used as claimed.

8. Claim 16 is rejected under 35 U \simeq C. 103(a) as being unpatentable over Eitan and Reisinger, as applied to Claim 13 above, and further in view of DiMaria (Journal de Physique 1981)

Eitan and Reisinger show most as: ects of the instant invention (Paragraph 7) except for the charge storage dielectric including silicon rich silicon dioxide. DiMaria teaches (e.g. Figure 3) to use a charge storage dielectric including silicon rich silicon dioxide to produce a memory device with excellent breakdown characteristics (Page C4-1117 second paragraph). It would have been obvious to a person of ordinary skill in the art at the time of invention to the act acharge storage dielectric including silicon rich silicon dioxide as taught by DiMar at in the device of Eitan and Reisinger to produce a memory device with excellent breakdown characteristics.

9. Claims 19, 21 to 26, 29 to 31 and 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ma et al. (U.S.) atent No. 5,278,439) and Reisinger.

Ma et al. show most aspects of the restant invention (e.g. Figures 2 and 3) including:

- → an array of memory cells 20. 2 with elongated source and drain regions 20A. 22A within a substrate 26 and extending in a first direction and separated in a second direction perpendicular c said first direction
- a channel region 22 extending tween said source/drain regions
- r first and second conductive sontrol) gates 20C, 22C extending in said first direction and first and second storage elements 20B, 22B
- conductive word lines 28 extending in said second direction
- a third control transistor gate 2. A positioned between said storage elements and channel 24G coupled by a gate dielectric to

Ma et al. shows do not show the storage of more then two defined ranges using charge storage dielectric. Reising teaches (e.g. Figure 1) to store four (Column 7 Lines 25 to 30) or more (Colum 6 Lines 5 to 35) ranges in a charge storage dielectric 52 in order to increase re storage density (Column 2 Lines 7 to 12). It would have been obvious to a person of ordinary skill in the art at the time of invention to store four or more ranges in a charge storage dielectric as taught by Reisinger in the device of Ma et a product to increase the storage density.

In reference to the claim language referring to how the cells are programmed (either by channel hot-electron or source side injection) and read, intended use and other types of functional language me t result in a structural difference between the claimed invention and the prior to in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the country in a claim drawn to a process of making, the intended use must result in a mar buildtive difference as compared to the prior art. In re Casey.152 USPQ 235 (CCP) 1967); In re Otto , 136 USPQ 458, 459 (CCPA 1963).

10 Claims 20 and 22 are rejected unlier 35 U.S.C. 103(a) as being unpatentable over Ma et al. and Reisinger, as appli∈ 10 Claim 19 above, and further in view of Eckert et al. (U.S. Patent No. 5,889,303,

Ma et al and Reisinger show in except for the charge trapping in 106 extend between two control g Lines 37 to 60). It would have bee the time of invention to have ch gates as taught by Eckert et al gate oxide stress.

· aspects of the instant invention (Paragraph 9) al extending continuously between two control gates. Eckert et al. teach (e.g. Frances 10 and 11) to have charge storage material es **110a,b** to reduce gate oxide stress (Column 2 obvious to a person of ordinary skill in the art at storage material extend between two control me device of Ma et al. and Reisinger to reduce

11. Claims 27, 32 and 33 are reject: under 35 U.S.C. 103(a) as being unpatentable over Ma et al. and Reisinger, as a collect to Claim 19 above, and further in view of Aritome et al. (IEDM 95).

Ma et al. and Reisinger show me et aspects of the instant invention (Paragraph 9) into the substrate. Aritome et al. teach (e.g. except for the word lines reces: ne substrate to realize a very low bit cost (see Figure 1) to recess word lines in: cus to a person of ordinary skill in the art at the Abstract). It would have been obtime of invention to recess word lines into the substrate as taught by Aritome et al. in to realize a very low bit cost. the device of Ma et all and Reisin

12. Claims 34 and 36 are rejected up set 35 U.S.C. 103(a) as being unpatentable over Ma et al. (U.S. Patent No. 6,346.7. 5 and hereinafter Ma '725) and Reisinger.

Ma 725 show most aspects of the stant invention (e.g. Figures 3) including:

- an array of memory cells S1 regions within a substrate 40 : second direction perpendicula
- a channel region 80 extending.
- conductive control lines 70 e. said source/drain regions in a
- conductive word lines 710 sp second direction over said cospace neighboring source/dra
- charge storage material 60 pc

S6 with elongated source 120 and drain 30 extending in a first direction and separated in a said first direction

- ween said source/drain regions
- ding in said first direction and adjacent one of st portion of space between said regions
- ed apart in said first direction, extending in said Hines and positioned over a second portion of egions
 - n between said word and control lines

Ma 725 shows do not show the dielectric charge storage materia Reisinger teaches (e.g. Figure 1 (Column 6 Lines 5 to 35) rang programming and reading means (Column 2 Lines 7 to 12). It would the art at the time of invention storage material using programs Reisinger in the device of Ma 72 prage of more then two defined ranges using d the explicit programming and reading circuits. store four (Column 7 Lines 25 to 30) or more n dielectric charge storage material 52 using claimed in order to increase the storage density ave been obvious to a person of ordinary skill in store four or more ranges in dielectric charge and reading means as claimed as taught by order to increase the storage density.

In reference to the claim language by channel hot electron or source types of functional language in claimed invention and the prior invention from the prior art. If the intended use, then it meets the C intended use must result in a mar re Casey.152 USPQ 235 (CC) 1963).

sferring to how the cells are programmed (either age injection) and read, intended use and other result in a structural difference between the on order to patentably distinguish the claimed prior art structure is capable of performing the In a claim drawn to a process of making, the lative difference as compared to the prior art. In 267); In re Otto , 136 USPQ 458, 459 (CCPA 13. Claim 35 is rejected under 35 t and Reisinger, as applied to Clau-

103(a) as being unpatentable over Ma 725 gabove, and further in view of Eckert et al.

Ma 725 and Reisinger show ma except for the charge trapping in gates Eckert et al. teach (e.g. F 106 extend between two control Lines 37 to 60). It would have be the time of invention to have cr gates as taught by Eckert et al gate oxide stress

aspects of the instant invention (Paragraph 12) at extending continuously between two control ...s 10 and 11) to have charge storage material 110a,b to reduce gate oxide stress (Column 2 bvious to a person of ordinary skill in the art at storage material extend between two control the device of Ma 725 and Reisinger to reduce

Respense to Arguments

14. The Applicants' arguments filed not persuasive. In reference to h functional or use limitation one. limitation translates to a significathe instant invention. As stated $\boldsymbol{\kappa}$ performing the intended use, the Prior Art meets this standard.

2/02 have been fully considered but they are e combination of references are programmed, e patentable weight in a device claim if the nuctural difference in the resultant device and rejection: "If the prior art structure is capable of : meets the claim." The stated combination of

15. The Applicants arguments with considered but are moot in view

eect to claims 20, 27, 28 and 32 have been he new ground(s) of rejection.

inclusion

the new ground(s) of rejection presented in this 16. Applicant's amendment necess: See MPEP ACTION IS MADE FINAL. Accordingly. 7. ... the extension of time policy as set forth in 37 Office action. § 706.07(a). Applicant is remine: CFR 1 136(a)

A shortened statutory period for MONTHS from the mailing date.

TWO MONTHS of the mailing date mailed until after the end of the shortened statutory period will enable any extension fee pursuant to 3 date of the advisory action. In the expire later than SIX MONTHS to

If this final action is set to expire THREE action. In the event a first reply is filed within this final action and the advisory action is not E-MONTH shortened statutory period, then the on the date the advisory action is mailed, and FR 1.136(a) will be calculated from the mailing event, however, will the statutory period for reply the date of this final action.

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- unication or earlier communications from the ard Weiss at (703) 308-4840 and between the n Standard Time) Monday through Friday or by

Any inquiry of a general nature directed to the Group 2800 Rec

lating to the status of this application should be nist at (703) 308-0956.

19. The following list is the Examine and of search for the present Office Action:

	Field of Scarch		Date
U.S. Class / Subcl	ass(es): 257/ 3. 6	thru	1/14/03
Other Documental	non none	Abril	1/14/03
Electronic Databa	se(s): EAST. IEL	thru	1714/00

HW/hw 15 January 2003 Howard Weiss Examiner Art Unit 2814

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